



Cite this: *Nanoscale*, 2018, **10**, 19638

## Correction: Giant resistive switching in mixed phase BiFeO<sub>3</sub> via phase population control

David Edwards,<sup>a</sup> Niall Browne,<sup>a</sup> Kristina M. Holsgrove,<sup>a</sup> Aaron B. Naden,<sup>a</sup> Sayed O. Sayedaghaee,<sup>b</sup> Bin Xu,<sup>c</sup> Sergey Prosandeev,<sup>c</sup> Dawei Wang,<sup>d</sup> Dipanjan Mazumdar,<sup>e</sup> Martial Duchamp,<sup>f,g</sup> Arunava Gupta,<sup>h</sup> Sergei V. Kalinin,<sup>i</sup> Miryam Arredondo,<sup>a</sup> Raymond G. P. McQuaid,<sup>a</sup> Laurent Bellaiche,<sup>c</sup> J. Marty Gregg<sup>a</sup> and Amit Kumar<sup>\*a</sup>

DOI: 10.1039/c8nr90215a  
[rsc.li/nanoscale](http://rsc.li/nanoscale)

Correction for 'Giant resistive switching in mixed phase BiFeO<sub>3</sub> via phase population control' by David Edwards *et al.*, *Nanoscale*, 2018, **10**, 17629–17637.

The authors have noticed that the name of one of the co-authors was spelt incorrectly in the originally published version of this article. 'Sayed O. Sayedghae' should have been spelt 'Sayed O. Sayedaghaee' as provided in the corrected author list above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

<sup>a</sup>School of Mathematics and Physics, Queen's University Belfast, Belfast, BT7 1NN, UK. E-mail: a.kumar@qub.ac.uk

<sup>b</sup>Microelectronics-Photonics Program and Physics Department, University of Arkansas, Fayetteville, Arkansas 72701, USA

<sup>c</sup>Physics Department and Institute for Nanoscience and Engineering, University of Arkansas, Fayetteville, Arkansas 72701, USA

<sup>d</sup>Electronic Materials Research Laboratory, Key Laboratory of the Ministry of Education and International Center for Dielectric Research, Xi'an Jiaotong University, Xi'an 710049, China

<sup>e</sup>Department of Physics, Southern Illinois University, Carbondale, Illinois 62901, USA

<sup>f</sup>Ernst Ruska Centre for Microscopy, Forschungszentrum Juelich, Juelich 52428, Germany

<sup>g</sup>School of Materials Science and Engineering, Nanyang Technological University, Singapore 639798, Singapore

<sup>h</sup>Center for Materials for Information Technology, University of Alabama, Tuscaloosa, Alabama 35487, USA

<sup>i</sup>Center for Nanophase Material Sciences, Oak Ridge National Laboratory, Oak Ridge, Tennessee, 37831, USA

